UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/554,397	09/26/2006	Yoshitake Natsume	279648US0PCT	2754
	7590 06/19/200 AK, MCCLELLAND I	9 MAIER & NEUSTADT, P.C.	279648US0PCT 2754 EXAMINER HAN, KWANG S ART UNIT PAPER NUMBER 1795	
1940 DUKE ST	REET	·		WANG S
ALEXANDRIA	A, VA 22314		ART UNIT PAPER NUMBER	
			1795	
			NOTIFICATION DATE	DELIVERY MODE
			06/19/2009	ELECTRONIC

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

patentdocket@oblon.com oblonpat@oblon.com jgardner@oblon.com

	Application No.	Applicant(s)				
Office Action Occurrence	10/554,397	NATSUME ET AL.				
Office Action Summary	Examiner	Art Unit				
	Kwang Han	1795				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence addr	ess			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 6(a). In no event, however, may a reply be timil apply and will expire SIX (6) MONTHS from cause the application to become ABANDONEI	l. lely filed the mailing date of this comr ○ (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on						
	<u> </u>					
3) Since this application is in condition for allowan						
closed in accordance with the practice under E.	x <i>parte Quayl</i> e, 1935 C.D. 11, 45	3 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>1-18</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdraw	n from consideration.					
5) Claim(s) is/are allowed.						
6) Claim(s) is/are rejected.						
7) Claim(s) is/are objected to.						
·	8)⊠ Claim(s)is/are objected to: 8)⊠ Claim(s) <u>1-18</u> are subject to restriction and/or election requirement.					
0) <u>23</u>	ioonen roquii omonii.					
Application Papers						
9)☐ The specification is objected to by the Examiner	. .					
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to the o	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the correction	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
11)☐ The oath or declaration is objected to by the Exa	aminer. Note the attached Office	Action or form PTO	-152.			
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 	s have been received. s have been received in Application	on No				
3. Copies of the certified copies of the priori		ed in this National St	age			
	application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.					
See the attached detailed Office action for a list of	or the certified copies not receive	u.				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08)	Paper No(s)/Mail Da 5) Notice of Informal Pa					
Paper No(s)/Mail Date	6) Other:					

NEGATIVE ELECTRODE FOR LITHIUM SECONDARY CELL, LITHIUM SECONDARY CELL EMPLOYING THE NEGATIVE ELECTRODE, FILM DEPOSITION MATERIAL B USED FOR FORMING NEGATIVE ELECTRODE, AND PROCESS FOR PRODUCING NEGATIVE ELECTRODE

Examiner: K. Han SN: 10/554,397 Art Unit: 1795 June 17, 2009

Election/Restrictions

1. Restriction is required under 35 U.S.C. 121 and 372.

This application contains the following inventions or groups of inventions which are not so linked as to form a single general inventive concept under PCT Rule 13.1.

In accordance with 37 CFR 1.499, applicant is required, in reply to this action, to elect a single invention to which the claims must be restricted.

Group I, claims 1-5, 7, and 12-14, drawn to a lithium secondary battery negative electrode having a thin film of silicon oxide formed by vacuum vapor deposition or sputtering on the surface of a collector.

Group II, claims 6 and 18, drawn to a lithium secondary battery negative electrode, being a SiO film type negative electrode having a capacity sustainability.

Group III, claims 8-11, drawn to a film forming material.

Group IV, claims 15-17, drawn to a fabricating method for a lithium secondary battery negative electrode with a cleaning treatment.

2. The inventions listed as Groups I-IV do not relate to a single general inventive concept under PCT Rule 13.1 because, under PCT Rule 13.2, they lack the same or corresponding special technical features for the following reasons: The common special technical feature present in all the groups is a negative electrode for a lithium secondary battery having a thin film of silicon oxide. This cannot be a special technical feature under PCT rule 13.2 because the feature is shown in the prior art. Hiroyuki et al. (JP

2002-042809, machine translation) discloses an electrode active material capable of storing and releasing ions comprised of SiOx [Abstract]. Yoichi et al. (JP 2001-210319, machine translation) teaches a method of forming an electrode for lithium secondary batteries by forming a thin film on the surface of a collector [0007, 0008]. It would have been obvious to one of ordinary skill in the art at the time of the invention to form the electrode of Hiroyuki using the method of forming a thin film because Yoichi teaches the formation of a thin film allows for sufficient adhesion on a charge collector, therefore presenting a lack of unity between the groups a posteriori.

Page 3

Applicant is advised that the reply to this requirement to be complete must include (i) an election of a species or invention to be examined even though the requirement may be traversed (37 CFR 1.143) and (ii) identification of the claims encompassing the elected invention.

The election of an invention or species may be made with or without traverse. To preserve a right to petition, the election must be made with traverse. If the reply does not distinctly and specifically point out supposed errors in the restriction requirement, the election shall be treated as an election without traverse.

3. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kwang Han whose telephone number is (571) 270-5264. The examiner can normally be reached on Monday through Friday 8:00am to 5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Dah-Wei Yuan can be reached on (571) 272-1295. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/K. H./ Examiner, Art Unit 1795

/Dah-Wei D. Yuan/ Supervisory Patent Examiner, Art Unit 1795